

IAP12 Rec'd PCT/PTO 05 MAY 2006

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Syo-ichi TAKAMIZAWA et al.

Application No.: New U.S. National Stage of PCT/JP2004/012179

Filed: May 5, 2006

Docket No.: 127101

For: METHOD FOR PRODUCING SILICON EPITAXIAL WAFER

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- ☒ 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- ☒ 2. Relevance of one or more non-English language reference is discussed in the present specification. See References 6 and 7.
- ☒ 3. One or more reference cited herein was cited in the International Search Report. An English language version of the International Search Report is attached for the Examiner's information. See References 3-5 and 7.
- ☒ 4. In accordance with 37 CFR §1.98(a)(2)(ii), copies of any U.S. patents and patent application publications are not attached.
- ☒ 5. An English language Abstract of one or more non-English language reference is attached hereto. See References 3-7.
- ☒ 6. A computer-generated English language translation of one or more Japanese Patent Publication cited herein has been obtained from the website of the Japanese Patent Office ([<http://www.jpo.go.jp>]), and is attached, but has not been reviewed for accuracy. See References 3, 5 and 7.

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- ☒ 7. Reference 1 corresponds to reference 4. Reference 2 corresponds to reference 5.

Respectfully submitted,



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Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 127101		APPLICATION NO. New U.S. National Stage of PCT/JP2004/012179	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANTS Syo-ichi TAKAMIZAWA et al.			
				FILING DATE May 5, 2006			
U.S. PATENT DOCUMENTS							
Examiner Initials	Cite No.	Document Number	Date	Name			
/RK/	1.	4,662,956	5/5/1987	Roth et al.			
/RK/	2.	6,013,564	1/11/2000	Muramatsu			
FOREIGN PATENT DOCUMENTS							
Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation	
/RK/	3.	JP A 11-100299	4/13/1999	JAPAN	X	X	
/RK/	4	JP A 62-502438	9/17/1987	JAPAN	X		
/RK/	5.	JP A 10-106955	4/24/1998	JAPAN	X	X	
/RK/	6.	JP A 58-41799	3/11/1983	JAPAN	X		
/RK/	7.	JP A 9-120947	5/6/1997	JAPAN	X	X	
OTHER DOCUMENTS							
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)					
EXAMINER /Robert Kunemund/				DATE CONSIDERED 03/11/2008			
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							